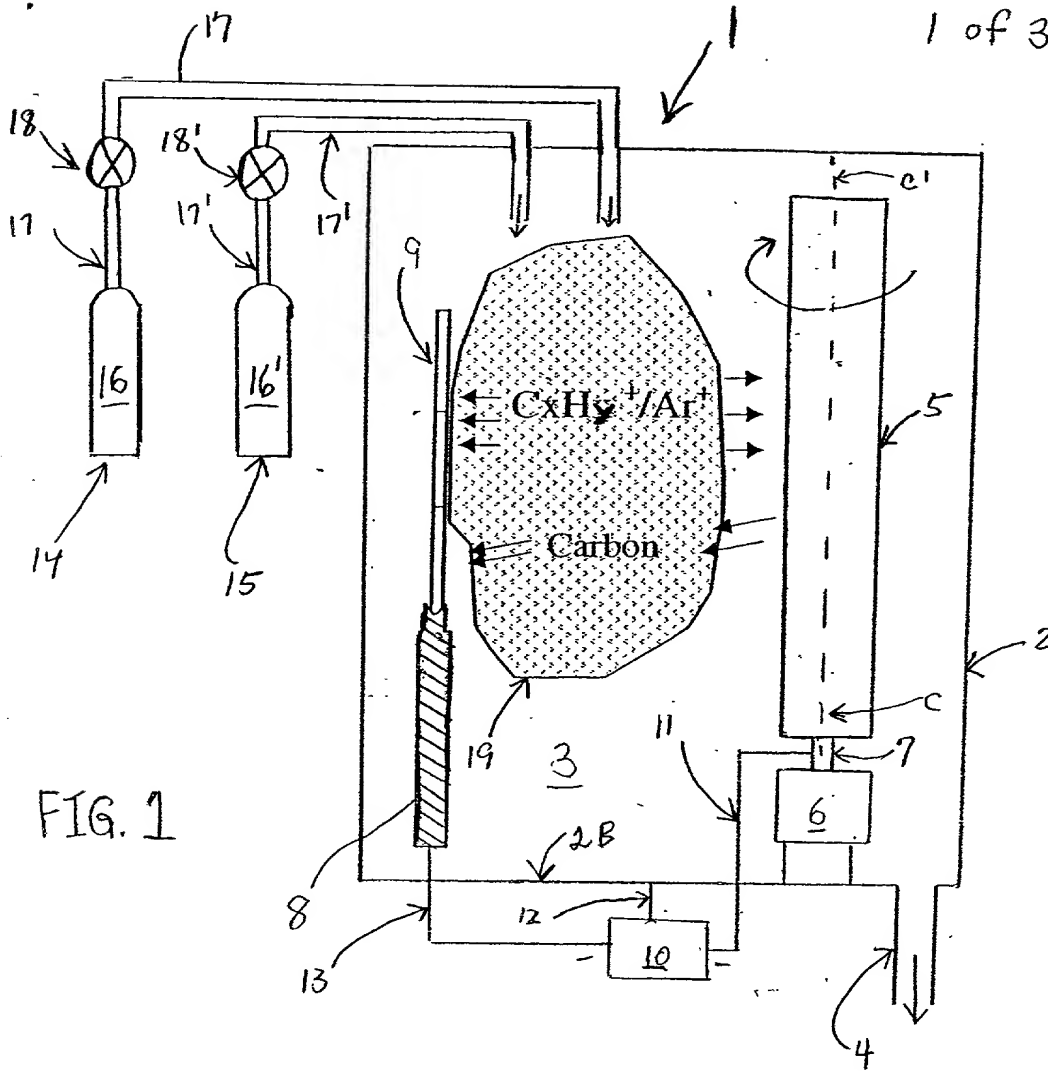


FIG. 1



Percentage Deposited Carbon from C₂H₂ vs C₂H₂ Flow
(Ar flow=146sccm, Pressure ~2.7mTorr)

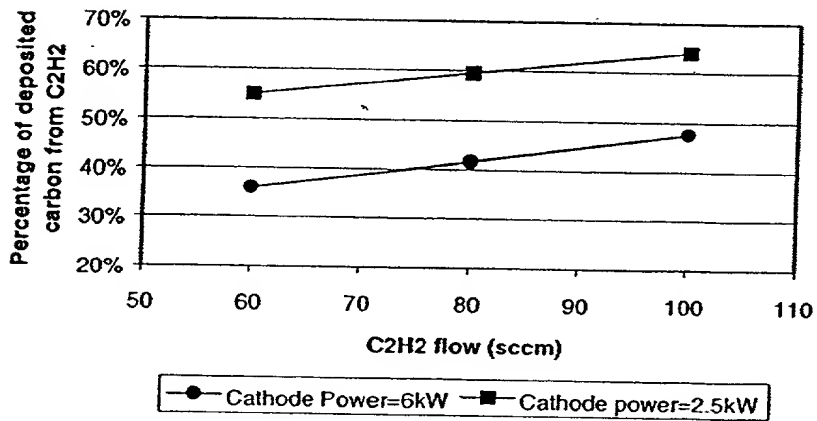


FIG. 2

50103 = 421

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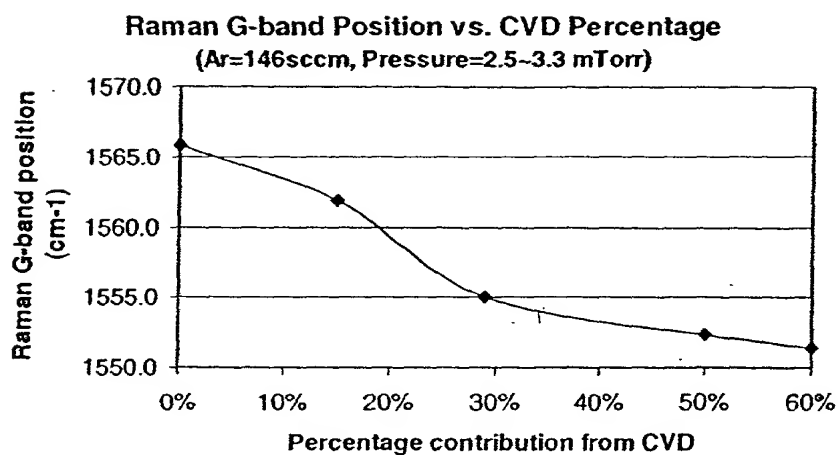


FIG. 3

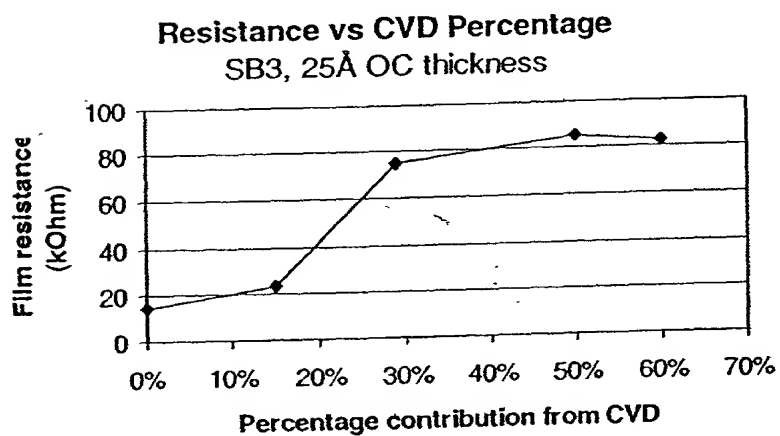


FIG. 4

50103=421

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Surface Mark vs C2H2 Contribution (F104026)

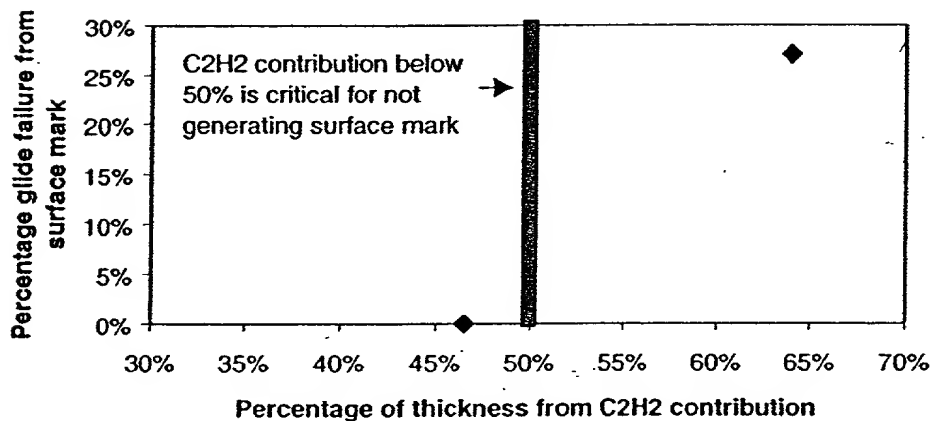


FIG. 5

CoOx Comparison of CVD-assisted Carbon and Sputter Carbon
(After 4 days 80C/80%RH stress)

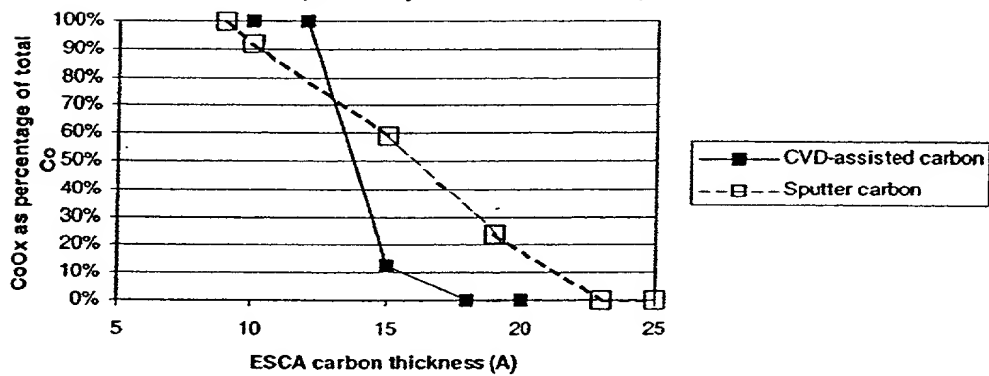


FIG. 6